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				Application Number	10/650,344
				Filing Date	August 28, 2003
				First Named Inventor	Sung-Yung Lee
				Group Art Unit	2828
				Examiner Name	Kevin Duinto
				Attorney Docket Number	5649-1162
Sheet	1A	of	1A		

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Examiner Signature	<i>Kenny Quinto</i>	Date Considered	8/5/15
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*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

**INFORMATION DISCLOSURE
STATEMENT BY APPLICANT**

Sheet

1A

of

18

Application Number

10/650,344

Filing Date

August 28, 2003

First Named Inventor

Sung-Yung Lee

Group Art Unit

2826

Examiner Name

Kevin Quintero

Attorney Docket Number

5649-1162

**Examiner
Initials***

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2002-0002599

Korean Application No. 10-2000-0036823; English Abstract

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Examiner Signature

Kevin Quigley

Date Considered

8/5/85

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